Notice of Allowability	Application No.	Applicant(s)	
	09/698,168	INOUE ET AL.	
	Examin r	Art Unit	
	DiLinh Nguyen	2814	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in or other appropriate commits (IGHTS). This application is	n this application. If not incli junication will be mailed in di	uded ue course. THIS
 This communication is responsive to 9/30/03. The allowed claim(s) is/are 35-50. The drawings filed on are accepted by the Examine 4 Acknowledgment is made of a claim for foreign priority und a) All b) Some* c) None of the: Certified copies of the priority documents have 2 Certified copies of the priority documents have 3 Copies of the certified copies of the priority do 	der 35 U.S.C. § 119(a)-(d) of the been received. be been received in Application	on No	cation from the
International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 5. Acknowledgment is made of a claim for domestic priority u (a) The translation of the foreign language provisional a 6. Acknowledgment is made of a claim for domestic priority u	nder 35 U.S.C. § 119(e) (to application has been receive	a provisional application).	
Applicant has THREE MONTHS FROM THE "MAILING DATE" of below. Failure to timely comply will result in ABANDONMENT of			
7. A SUBSTITUTE OATH OR DECLARATION must be subn INFORMAL PATENT APPLICATION (PTO-152) which gives reas			r NOTICE OF
 8. ☐ CORRECTED DRAWINGS must be submitted. (a) ☐ including changes required by the Notice of Draftsper 1) ☐ hereto or 2) ☐ to Paper No (b) ☐ including changes required by the proposed drawing (c) ☐ including changes required by the attached Examiner 	correction filed, whi	ch has been approved by the	
Identifying indicia such as the application number (see 37 CFR 1 each sheet.	.84(c)) should be written on (the drawings in the front (not	the back) of
 DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT FOR T 	sit of BIOLOGICAL MAT HE DEPOSIT OF BIOLOG	ERIAL must be submitted ICAL MATERIAL.	I. Note the
Attachment(s)			
 Notice of References Cited (PTO-892) Notice of Draftperson's Patent Drawing Review (PTO-948) Information Disclosure Statements (PTO-1449), Paper No Examiner's Comment Regarding Requirement for Deposit of Biological Material 	4⊡ Intervie 6⊠ Examin	of Informal Patent Application w Summary (PTO-413), Pap er's Amendment/Comment er's Statement of Reasons fo	er No
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Application/Control Number: 09/698,168

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DETAILED ACTION

EXAMINER'S AMENDMENT

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Mr. Gregory E. Montone on 9/30/03.

In the claims:

in line 10 of claim 35, after "wherein the", insert -electrically--;

in line 11 of claim 35, after "a flat portion of the", insert –electrically--;

in line 11 of claim 35, delete "an inclined" and insert –the inclined--;

in line 12 of claim 35, delete "a flat portion' and insert -the flat portion--;

in line 11 of claim 49, after "flat portion of the", insert -electrically--;

in line 11 of claim 49, after "layer", insert –near a boundary between the inclined portion and the flat portion--;

in line 10 of claim 50, after "a flat portion of the", insert -electrically--;

in line 10 of claim 50, after "layer", insert –near a boundary between the inclined portion and the flat portion--; and

cancel the non-elected claims: 1-11 and 13-22.

REASONS FOR ALLOWANCE

Claims 35-50 are allowed.

The following is an examiner's statement of reasons for allowance:

Shimoishizaka et al. fail to disclose the combination of all the limitations recited, including the electrically insulating layer has a protrusive portion which is higher than a flat portion of the electrically layer near a boundary between the inclined portion and the flat portion having a substantially uniform thickness and wherein a part of the wiring is formed on the protrusive portion, and the wiring comprises a copper and a nickel layer formed on the copper layer.

Tokunoh fails to disclose the combination of all the limitations recited, including the electrically insulating layer has a protrusive portion which is higher than a flat portion of the electrically layer near a boundary between the inclined portion and the flat portion having a substantially uniform thickness and wherein a part of the wiring is formed on the protrusive portion.

Therefore, the amended limitations together with the overall structure of the semiconductor apparatus is neither anticipated nor rendered obvious over the prior art of record.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to DiLinh Nguyen whose telephone number is (703) 305-6983. The examiner can normally be reached on 8:00AM - 6:00PM (M-F).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (703) 308-4918. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 308-7722 for regular communications and (703) 308-7724 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

DLN October 17, 2003